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Synthesis and Photonics of Nanoscale Materials VIII

**David B. Geohegan
Jan J. Dubowski
Frank Träger**
Editors

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Contents

- v *Conference Committee*
- vii *Microfabrication by optical tweezers (Plenary Paper) [792102]*
R. Ghadiri, T. Weigel, C. Esen, A. Ostendorf, Ruhr-Univ. Bochum (Germany)

SESSION 1 LASER SYNTHESIS AND SPECTROSCOPY OF NANOWIRES AND NANOTUBES

- 7922 03 **Fabrication of layer structured ZnO nanowire by nanoparticle-assisted pulsed laser deposition for optoelectronic application [7922-02]**
D. Nakamura, A. Kumeda, K. Toya, K. Okazaki, K. Kubo, K. Tsuta, M. Higashihata, T. Okada, Kyushu Univ. (Japan)
- 7922 06 **Single walled carbon nanotubes: a model system for excitons in one dimension (Invited Paper) [7922-05]**
J. Lefebvre, P. Finnie, National Research Council Canada (Canada)

SESSION 2 NANOPARTICLE SYNTHESIS AND BIOAPPLICATIONS

- 7922 08 **Photothermal mediated transformation of carbon nanoparticles [7922-07]**
N. Ingle, V. Varadraj, S. K. Mohanty, A. R. Koymen, The Univ. of Texas at Arlington (United States)

SESSION 3 FRONTIERS IN PLASMONICS

- 7922 0B **Surface plasmon lasers [7922-10]**
H. Grebel, New Jersey Institute of Technology (United States)
- 7922 0C **Tailoring the interaction between matter and polarized light with plasmonic optical antennas (Invited Paper) [7922-11]**
P. Biagioni, Politecnico di Milano (Italy); X. Wu, Julius-Maximilians-Univ. Würzburg (Germany); M. Savoini, Politecnico di Milano (Italy); J. Ziegler, Julius-Maximilians-Univ. Würzburg (Germany); J.-S. Huang, National Tsing Hua Univ. (Taiwan); L. Duò, M. Finazzi, Politecnico di Milano (Italy); B. Hecht, Julius-Maximilians-Univ. Würzburg (Germany)
- 7922 0D **Chemical damping of the localized surface plasmon polariton resonance: influence of different chemical environments [7922-12]**
F. Hubenthal, F. Träger, Univ. Kassel (Germany)

SESSION 4 CONTROLLING LASER INTERACTIONS AT THE NANOSCALE

- 7922 0G **Nanostructure formation by self-assembled monolayers: influence of the isomerization state of azobenzene ligands on monolayer formation** [7922-15]
F. Vogel, F. Bretthauer, U. Siemeling, F. Träger, Univ. Kassel (Germany)
- 7922 0H **Hyperspectral plasmonics** [7922-16]
D. Lepage, A. Jiménez, J. J. Dubowski, Univ. de Sherbrooke (Canada)

SESSION 5 POSTER SESSION

- 7922 0L **Atomic layer deposition of amorphous TiO₂/ZnO multilayers for soft x-ray coherent optics** [7922-20]
Y. Sanjo, M. Murata, Y. Tanaka, H. Kumagai, Osaka City Univ. (Japan); M. Chigane, Osaka Municipal Technical Research Institute (Japan)
- 7922 0M **Lasing and laser-induced motion of zinc oxide nano-crystals irradiated by ultraviolet laser beam** [7922-21]
K. Okazaki, D. Nakamura, M. Higashihata, T. Okada, Kyushu Univ. (Japan)

Author Index

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- 1 Laser Synthesis and Spectroscopy of Nanowires and Nanotubes
David B. Geohegan, Oak Ridge National Laboratory (United States)
- 2 Nanoparticle Synthesis and Bioapplications
Jan J. Dubowski, Université de Sherbrooke (Canada)

- 3 Frontiers in Plasmonics
Frank Träger, Universität Kassel (Germany)
- 4 Controlling Laser Interactions at the Nanoscale
Alex A. Puretzky, Oak Ridge National Laboratory (United States)